

## UNITED STATES PATENT AND TRADEMARK OFFICE



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APPLICATION NO.	FILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO.	
09/661,666	09/14/2000	Jianmin Qiao	5298-04100/PM00012	5298-04100/PM00012 9202	
35617	7590 03/03/2004		EXAMINER		
CONLEY ROSE, P.C.			PHAM, THANHHA S		
P.O. BOX 68 AUSTIN, TX			ART UNIT PAPER NUMBER		
11001111, 12	1 70700		2813		
•			DATE MAILED: 03/03/2004	DATE MAILED: 03/03/2004	

Please find below and/or attached an Office communication concerning this application or proceeding.

•			
	Application No.	Applicant(s)	
Advisory Action	09/661,666	QIAO ET AL.	
nancon y nouch	Examiner	Art Unit	
	David L. Hogans	2813	
The MAILING DATE of this communication appe	ears on the cover sheet with the	correspondence addre	ss
THE REPLY FILED December 31, 2003, FAILS TO PLATHER TO PLATHER FOR FILED DECEMBER 31, 2003, FAILS TO PLATHER FOR FILED DECEMBER STATES TO PLATHER TO PLATH	ivoid abandonment of this appli 1) a timely filed amendment wh	cation. A proper reply ich places the applica	y to a tion in
PERIOD FOR RE	EPLY [check either a) or b)]		
a) The period for reply expiresmonths from the mailing			
b) The period for reply expires on: (1) the mailing date of this Advevent, however, will the statutory period for reply expire later the ONLY CHECK THIS BOX WHEN THE FIRST REPLY WAS 706.07(f).  Extensions of time may be obtained under 37 CFR 1.136(a). The data have been filed is the date for purposes of determining the period of exten 37 CFR 1.17(a) is calculated from: (1) the expiration date of the shortened (b) above, if checked. Any reply received by the Office later than three moterand patent term adjustment. See 37 CFR 1.704(b).	an SIX MONTHS from the mailing date of FILED WITHIN TWO MONTHS OF THate on which the petition under 37 CFR 1, sion and the corresponding amount of the distatutory period for reply originally set in	of the final rejection.  E FINAL REJECTION. Sec  136(a) and the appropriate extended the final Office action; or (2)	extension fee nsion fee under ) as set forth in
1. A Notice of Appeal was filed on Appellant' 37 CFR 1.192(a), or any extension thereof (37 CF			
2. The proposed amendment(s) will not be entered be	ecause:		
(a) X they raise new issues that would require furth	er consideration and/or search	(see NOTE below);	
(b) they raise the issue of new matter (see Note			
(c) they are not deemed to place the application issues for appeal; and/or	in better form for appeal by ma	terially reducing or sir	nplifying the
(d) they present additional claims without cance	ling a corresponding number of	finally rejected claims	s.
NOTE: See Continuation Sheet.			
3. Applicant's reply has overcome the following rejection	ction(s):		
4. Newly proposed or amended claim(s) would canceling the non-allowable claim(s).	l be allowable if submitted in a s	separate, timely filed	amendment
5. ☐ The a) ☐ affidavit, b) ☐ exhibit, or c) ☐ request for application in condition for allowance because: _	or reconsideration has been con	sidered but does NOT	place the
6. The affidavit or exhibit will NOT be considered be raised by the Examiner in the final rejection.	cause it is not directed SOLELY	to issues which were	enewly
7. For purposes of Appeal, the proposed amendmen explanation of how the new or amended claims w	• • •	•	nd an
The status of the claim(s) is (or will be) as follows:			
Claim(s) allowed: None.			
Claim(s) objected to: None.			
Claim(s) rejected: 1-5,7-12 and 14-16.			
Claim(s) withdrawn from consideration: None.			
8. The drawing correction filed on is a) app	proved or b) disapproved by	the Examiner.	
9. Note the attached Information Disclosure Stateme	ent(s)( PTO-1449) Paper (s).	1 May hand	/
10. Other:	Elli	Conjunition	5
	SUPERVIS	IL WHITEHEAD, JR. SORY PATENT EXAMINER OLOGY CENTER 2800	,

U.S. Patent and Trademark Office PTOL-303 (Rev. 11-03) Continuation Sheet (PTOL-303) 09/661,666

Application No.

Continuation of 2. NOTE: The limitation of changing gases supplied to an etch chamber such that gases of the first etch chemistry are present in negligible quantities during the step of etching the second portion of the dielectric layer raises new issues that would require further consideration and/or search.